Special Issue

Theory and Modelling of Nanomechanical Systems Application in the Biomedical Field

Message from the Guest Editors

This Special Issue aims to inventory the latest achievements in theory and modelling of nanomechanical systems and welcomes papers concerning innovation and development in theory, methods and modelling of new devices with application in the biomedical field. Keywords

- Nanotechnology
- Biomedicine
- Biosensors
- Mechanics
- Theory
- Modellina

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